

### Towards the Mu3e Pixel Tracker with MuPix11: Construction & Performance Studies

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### Mu3e: Physics Motivation





- Search for the cLFV decay  $\mu^+ \rightarrow e^+e^-e^+$ (vSM: BR < 10<sup>-54</sup>)
- Current limit (SINDRUM) BR < 10<sup>-12</sup> @ 90% CL
- Sensitivity goal (Phase1): 1 in 10<sup>15</sup> decays
- Up to 10<sup>8</sup> decays per second
- Suppress background below sensitivity level



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### Experimental sensitivity



Invariant mass of signal decay, radiative decay and accidental background (Bhabha+Michel)

Momentum resolution crucial for detecting the peak at muon mass...

Material budget is key factor!

1 MeV resolution with 0.1% \* X/X $_0$  per layer

Mu3e TDR at Nucl.Instrum.Meth.A 1014, 165679



- 10<sup>8</sup> decays per second
- $p_{max} = m_{\mu}/2 = 53 \text{ MeV}$ 
  - Multiple Coulomb Scattering
  - Triplet Fit
     [arXiv:1606.04990v2]

- Good vertex and time resolution (100 µm & 500 ps)
- Excellent momentum resolution (0.5 MeV)
- Continuous Beam! No trigger!
  - Online reconstruction and selection

Helium Gas Cooling arXiv:2301.13813, arXiv:2307.14803



Spatial resolution dominates

Scattering dominates

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### The Mu3e Detector

Pixel detector requirements:

Pixel Size	Time Resolution	Material Budget	Efficiency
80 x 80 µm²	< 20 ns	0.1% X <sub>0</sub> /layer	> 99 %

Mu3e TDR [arXiv:2009.11690]

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#### Tracking System - Vertex Detector Layer 0+1



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Flexprint

# High Voltage - Monolithic Active Pixel Sensors

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- Commercial HV-CMOS processes: TSI 180nm (h18)
- Deep N-well diode
- Low Ohmic substrates (10-400  $\Omega$ cm)
- High voltages up to 100V
- Charge collection via drift

- **In-pixel electronics**
- Monolithic design: • Detection and Readout combined in one chip





### MuPix/HV-MAPS R&D process





### **MuPix Architecture**





- Clear separation of analog and digital electronics
- 2 comparator design
- Tuning/Trimming and masking available
- Priority encoder / column-drain readout
- Chip sub-divided into 3 matrices  $\rightarrow$  1 Data link each + 1 multiplexed link





- Deposited charge amplified by in-pixel amplifier
- Source follower drives the signal to the periphery
- Digitisation in periphery
- . Timestamp sampling
- Readout statemachine manages
   column-drain readout
- Data is send out via a 1.25 Gbit/s differential link

Courtesy: Frank Meier





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### MuPix10 & MuPix11



Pixel size [µm²]	80 x 80				
Sensor size [mm <sup>2</sup> ]	20.66 x 23.18				
Active size [mm <sup>2</sup> ]	20.48 x 20.0				
Pixel matrix	256 x 250				
Thickness [µm]	50, 70				
Substrate [Ωcm]	80, 370				
Data links	3+1				
Data speed [Gbit/s]	1.25				
Time-of-arrival [bits]	11				
ToT [bits]	5				
TS binning [ns]	8 (option for 1.6)				



## From MuPix10 to MuPix11



- Removal of R&D features
  - → More pads for powering
- Improvement of powering grid
  - Less on-chip voltage drop
- Buffering of data lines
  - Full speed readout
     30 MHits/s per sub-matrix
- Re-synthesis of State machine
  - ➡ Fast configuration interface available
- Re-done pixel point-to-point connection
  - ➡ Reduced delays and parasitic couplings



### **Sensor Characterisation**







- Lab commissioning
- Lab optimisation: Radioactive sources: <sup>55</sup>Fe, <sup>90</sup>Sr Time coincidence
- Testbeam Campaigns: DESYII (Hamburg, GER) MAMI (Mainz, GER) PSI piM1 (Villigen, CH)
- MuPix-Telescope
- Mimosa/Alpide-Telescopes



tuned

untuned

#### Summary - Results MuPix10





a 1800 -

1600

1400

1200

1000E

+++ tuned, VPDAC = 0x6

untured VPDAC = 0x0

unturned VPDAC = 0x6



#### [arXiv:2012.05868] & VERTEX2022



#### MuPix11 - First Light





### MuPix11 - Efficiency for 50 and 70 $\mu m$



Mu3e: 50µm sensors for the vertex detector (~100 Sensors) 70µm sensors for the outer layers (~3000 Sensors)



#### MuPix11 - High Rate capability

MAMI - Beam spot on sub-matrix A

Beam rate measured with MuPix11



No Readout saturation visible @ 4 MHz Hitrate

Average Rate on "Hottest" Sensor 6 MHz



## MuPix Fast Configuration Interface



- Chips of a ladder share a bus of clock, synchronous reset and configuration input
- Custom configuration protocol
- Commands interleavable
- ~400ms configuration time for 9 chip ladder
- Detector currently configurable < 4s
- ADC data sent out via regular data links

SIn		Input data		Input data	Γ	Input data			Input data
Chip0	Idle	Read & Interpret	Execute Task			(Idle )	Read & Interpret		
Chip1	Idle	Read & Interpret	Idle	Read & Interpret		Execute Task		āsk χ	
Chip3	Idle	Read & Interpret	Idle	Read & Interpret	Idle	χ	Execute Task		
Chip4	Idle	Read & Interpret	Idle	Read & Interpret	Idle	χ	Execute Task		



### **On-Chip Temperature Measurement**





# (Pre-)Production Status



#### In-House Wafer Handling

- Diced and thinned wafers delivered, on tape
- Equipement:
  - Vacuum chuck
  - Pick-up tools (tweezer & suction pen)
  - A lot of patience & time
- Pending on use case thickness vary between 50µm to 100µm + 750µm







#### **Proto Vertex Detector**



- Two layer vertex detector (MuPix10)
  - Gain operational experience
  - Test Mu3e readout chain

- First proto-detector with 6 chips modules
  - Still PCB based!!!





### Operation in experimental conditions

DAQ and experimental concept





#### Operation in experimental conditions

With beam (2021)

With cosmics (2022)





### Quality Control (QC)

- Quality assurance is key before a large scale detector assembly
- Testing after assembly is too risky and costly, since dismantling is impossible
- Press down mechanism with contact needles for prior testing







#### QC - Test procedures



- 2 Single Chip test sites
- First needle card test station being setup in Oxford
- QC procedure still being refined, but almost final
- Grading scheme still adjusting (pre-production)



#### The Vertex Detector



- First Vertex ladders have been produced
- Ladder QC under development in parallel to single chip QC
- Fully functional 50µm ladder in Hand
- Currently running beam time at PSI: First time in-beam commissioning of final ladder





### Summary & Outlook

- Successful transition from MuPix10 to MuPix11
  - Everything functional, expected to fulfill Mu3e requirements
- QC procedures have been developed and implemented
  - First successful test of needle card for large volume testing
- Production of Vertex ladders started
  - First in-beam test still this week
  - Full vertex detector expected in Spring
- First ladders of outer pixel layers expected in Spring
- Start with detector commissioning next year





# Backup



#### cLFV - Landscape





#### **PSI - Beamline Upgrades**

#### **IMPACT** Timeline



![](_page_41_Picture_0.jpeg)

#### Quad - Module Telescope

![](_page_41_Picture_2.jpeg)

![](_page_41_Picture_3.jpeg)

![](_page_42_Picture_0.jpeg)

## A MuPix Module

- Chips glued and SpTAB-bonded to flexprint
- No additional components!
- 1.15‰ X<sub>0</sub> per layer
- Minimize dead space between the chips
- Only 11 µm dead silicon outside the guardring
- Power consumption limited to 400 mW/cm<sup>2</sup> (Sensors+Flex)

![](_page_42_Figure_8.jpeg)

![](_page_43_Picture_0.jpeg)

## The Flexprint Environment

- 2 layer aluminum polyimide flexprint (LTU)
- Provides:
   Power & HV (parallel)
   Differential Signal I/O
- Only 1 supply voltage, but no LDO-regulators!
- Minimise I/O
- Flex design rules define PadOut

![](_page_43_Figure_7.jpeg)

![](_page_43_Figure_8.jpeg)

## **On-chip ADC**

![](_page_44_Figure_2.jpeg)

- ADC programmable through Mu3e configuration interface
- Allows measurement of on-chip voltages
- Data send out via 1.25 Gbit/s data links
- . ADC shows a nice linearity

![](_page_45_Picture_0.jpeg)

### Signal Line Crosstalk - MuPix8

![](_page_45_Figure_2.jpeg)

![](_page_45_Figure_3.jpeg)

Triple Crosstalk: hit induced in both neighbouring lines

![](_page_46_Picture_0.jpeg)

## Routing Optimisation - MuPix10

![](_page_46_Figure_2.jpeg)

- Equalize but reduce crosstalk

   →miminise the length that two line are neighbouring
   (¼ of total length, 2cm)
- ~12% triple crosstalk expected
- Make Crosstalk easily detectable
   → neigbouring signal lines are not
   neigbouring pixels
- Crosstalk can be removed, possibly already during the data taking
- Even more improvement expected for MuPix11

![](_page_47_Picture_0.jpeg)

### Beyond MuPix11 – Roadmap -- Architectures

![](_page_47_Figure_2.jpeg)

![](_page_47_Figure_3.jpeg)

![](_page_47_Figure_4.jpeg)

![](_page_47_Figure_5.jpeg)

![](_page_48_Picture_0.jpeg)

#### Production of inner layers

![](_page_48_Picture_2.jpeg)

#### Heidelberg/PSI

Quick demo: <a href="https://youtu.be/0SYqHSbH3U4">https://youtu.be/0SYqHSbH3U4</a>

![](_page_48_Picture_5.jpeg)

![](_page_49_Picture_0.jpeg)

#### Production of outer layers

![](_page_49_Picture_2.jpeg)

#### **Oxford/Bristol/Liverpool**

![](_page_49_Picture_4.jpeg)